PATENT/OFFICIAL

Docket 100: 006365 USA/MTCG/PCTRL

1 1 2004 SAN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Yuri KOKOTOV et al.

Serial No. 10/712,273

Group Art Unit:

Filed: November 14, 2003

Examiner:

For: METHOD, SYSTEM AND MEDIUM FOR CONTROLLING MANUFACTURE PROCESS HAVING MULTIVARIATE INPUT PARAMETERS

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner for Patents P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom. Copies of any cited U.S. Patents and U.S. Patent Publications are not being submitted in accordance with 37 CFR 1.98(a)(2)(i).

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

In accordance with 37 C.F.R. § 1.97(g) and (h), the filing of this IDS should not be construed as a representation that a search had been made or that information cited is, or is considered to be, material to patentability as defined in 37 C.F.R.§ 1.56 (b), or that any cited document listed or attached is (or constitutes) prior art. Unless otherwise indicated, the date of

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publication indicated for an item is taken from the face of the item, and Applicant reserves the right to prove that the date of publication is in fact different.

No fee is believed to be required; however, the Commissioner is authorized to charge any deficiency in any fees pursuant to 37 CFR § 1.17 associated with this communication and to credit any excess payment to Deposit Account No. 08-0219.

Respectfully submitted,

WILMER CUTLER PICKERING HALE AND DORR LLP

Registration No. 32,879

1455 Pennsylvania Avenue, NW

Washington, DC 20004

TEL 202.942.8428 SMA/lrm

FAX 202.942.8484

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| CITATION IN AN | | | | MTCG/PCTRL | | | |
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ATTY. DOCKET NO. SERIAL NO. INFORMATION DISCLOSURE 006365 USA/ 10/712,273 CITATION IN AN MTCG/PCTRL APPLICATION (PTO-1449) APPLICANT Yuri KOKOTOV et al. FILING DATE GROUP November 14, 2003 U.S. PATENT DOCUMENTS **EXAMINER'S FILING** PATENT NO. DATE **SUBCLASS** DATE **INITIALS** NAME **CLASS** 11/13/01 03/31/99 6,317,643 B1 Dmochowski 6,339,727 B1 01/15/02 12/21/98 Ladd 6,355,559 B1 03/12/02 Havemann et al. 11/03/00 6,391,780 B1 05/21/02 Shih et al. 08/23/99 6,417,014 B1 07/09/02 10/19/99 Lam et al. 6,427,093 B1 07/30/02 10/07/99 Toprac 6,432,728 B1 08/13/02 Tai et al. 10/16/00 01/04/00 6,449,524 B1 09/10/02 Miller et al. 6,455,415 B1 09/24/02 Lopatin et al. 04/16/01 2002/0165636 A1 11/07/02 Hasan 04/24/02 11/19/02 6,484,064 B1 Campbell 10/05/99 6,495,452 B1 12/17/02 08/18/99 Shih 2002/0193899 A1 12/19/02 05/01/02 Shanmugasundram et al. 2003/0017256 A1 01/23/03 Shimane 06/12/02 6,515,368 B1 02/04/03 12/07/01 Lopatin et al. 03/10/00 6,517,414 B1 02/11/03 Tobin et al. 6,528,409 B1 03/04/03 Lopatin et al. 04/29/02 6,537,912 B1 03/25/03 08/25/00 Agarwal 6,580,958 B1 06/17/03 Takano 11/22/99 6,605,549 B2 08/12/03 09/29/01 Leu et al. 6,607,976 B2 08/19/03 09/25/01 Chen et al. 07/14/00 6,609,946 B1 08/26/03 Tran 04/05/01 6,616,513 B1 09/09/03 Osterheld 6,624,075 B1 09/23/03 Lopatin et al. 11/05/02 6,630,741 B1 10/07/03 12/07/01 Lopatin et al. 6,660,633 B1 12/09/03 Lopatin et al. 02/26/02 03/16/04 Chi et al. 08/11/00 6,708,074 B1 6,708,075 B2 03/16/04 Sonderman et al. 11/16/01 6,728,587 B2 04/27/04 12/27/00 Goldman et al. **EXAMINER** DATE CONSIDERED

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